The 2010 International Meeting for Future of Electron Devices, Kansai (IMFEDK2010) のご案内

日時: 2010年5月13日（木）～5月14日（金）／May 13-14, 2010
場所: 関西大学100周年記念会館／Kansai University Centenary Memorial Hall, Osaka, Japan
URL: http://www.imfedk.org/ (Official Language: English)

■ Keynote Speeches
[May 13, pm]
[1] "Advanced Electronics for Medical Applications (Tentative)", Manami Tanaka (AIST)

[May 14, am]
[3] "Future Prospects of Nano-Scale Transistors for VLSI Applications", Toshiro Hiramoto (The University of Tokyo)

■ Invited Papers for the Special Session [May 14, pm]
[2] "Integrated MEMS Sensors (Tentative)", Masafumi Kimata (Ritsumeikan University)

■ Tutorials (in Japanese) [May 13, am]
[1] "酸化亜鉛の結晶成長とデバイス応用", 佐々 誠彦（大阪工業大学）
[2] "CMOS-LSI 低電力化技術", 篠原 尋史（STARC）